

Electronic Supplementary Information

Experimental Section

Materials: Ti mesh was provided by Hangxu Filters Flag Store, Hengshui, Hebei. and $K_2B_4O_7 \cdot 4H_2O$, NaOH, $RuCl_3 \cdot 3H_2O$, and $Co(NO_3)_2 \cdot 6H_2O$ were purchased from Aladdin Ltd. (Shanghai, China). Nafion (5 wt%) was purchased from Sigma-Aldrich. All the reagents were used as received. The water used throughout all experiments was purified through a Millipore system.

Preparation of α -Co(OH)₂/Ti: Before electrodeposition, Ti mesh was firstly washed with HCl, ethanol, and water several times. The electrodeposition solution contained 0.05 M $Co(NO_3)_2 \cdot 6H_2O$. The deposition was performed in a three-electrode system by a CHI 660E electrochemical analyzer (CH Instruments, Inc. Shanghai), using a graphite plate as the counter electrode, Hg/Hg₂Cl₂ (SCE) as the reference electrode, and the cleaned Ti mesh (1 × 4 cm²) as the working electrode. The experiment was performed at room temperature (25 °C). The electrodeposition of α -Co(OH)₂ nanosheets by cyclic voltammetry (CV) was performed within the potential window from -1.2 V to -0.8 V vs. SCE with a scan rate of 50 mV • s⁻¹. After deposition for 50 scan cycles, the as-prepared electrode was rinsed first with deionized water, ethanol for several times and then dried at 60 °C for 12 h in vacuum oven. The sample was annealed at 350 °C in air for 2 h to obtain the Co₃O₄ nanosheets array.

Preparation of Co-Bi/Ti: To obtain Co-Bi/Ti, the α -Co(OH)₂/Ti electrode as the working electrode performed by cyclic voltammetry in 0.1 M KBi (pH 9.2) until the current density levelled off, with the graphite plate as the counter electrode and SCE as the reference electrode.

Electrochemical measurements: Electrochemical measurements were performed with a CHI 660E electrochemical analyzer (CH Instruments, Inc., Shanghai) in a conventional three-electrode system. Graphite plate, SCE, and Co-Bi/Ti were used as counter, reference and working electrodes, respectively. Overpotentials (η) were

calculated by the following equation: $\eta = E \text{ (RHE)} - 1.23 \text{ V}$, where $E \text{ (RHE)} = E \text{ (SCE)} + (0.242 + 0.059 \text{ pH}) \text{ V}$. Polarization curves were obtained using linear sweep voltammetry with a scan rate of 2 mVs^{-1} in 0.1M KBi electrolyte. All experiments were carried out at room temperature (298 K).

Characterizations: Powder X-ray powder diffraction (XRD) data of the samples were collected on Bruker D8 ADVANCE Diffractometer ($\lambda=1.5418 \text{ \AA}$). The scanning electron microscopy (SEM) measurements were performed on a XL30 ESEM FEG scanning electron microscope at an accelerating voltage of 20 kV . Transmission electron microscopy (TEM) measurements were performed on a HITACHI H-8100 electron microscopy (Hitachi, Tokyo, Japan) with an accelerating voltage of 200 kV . X-ray photoelectron spectroscopy (XPS) measurements were collected with a Thermal ESCALAB 250 spectrometer using an Al $K\alpha$ X-ray source (1486.6 eV photons).

Double layer capacitance (C_{dl}) measurements: To measure the electrochemical capacitance, the potential was swept between 1.13 to 1.23 V vs. RHE at different scan rates ($60, 80, 100, 120, 140, 160,$ and 180 mV s^{-1}) with an assumption of double layer charging in the potential range. The capacitive currents at 1.19 V vs. RHE were measured and plotted as a function of scan rate. A linear fit determined the double layer capacitance to be $122 \text{ \mu F cm}^{-2}$.

Turn over frequency (TOF) calculations: To compare the activity of Co-Bi with other non-noble-metal catalysts, we make a rough estimation of TOF for each active site using the following equation:

$$\text{TOF} = \text{JA}/4\text{F m}$$

Where J is current density (A cm^{-2}) at defined overpotential during the LSV measurement in 0.1 M K-Bi ; A is the geometric area of the electrode; 4 indicates the mole of electrons consumed for evolving one mole of O_2 from water; F is the Faradic constant (96485 C mol^{-1}); m is the number of active sites (mol), which can be extracted from the linear relationship between the oxidation peak current and scan rate using the following equation:

$$\text{Slope} = n^2\text{F}^2\text{A}\Gamma_0/4\text{RT}$$

where n is the number of electrons transferred; F is the Faradic constant; A is the surface area of the electrode; Γ_0 is the surface concentration of active sites (mol cm^{-2}); R and T are the ideal gas constant and the absolute temperature, respectively.

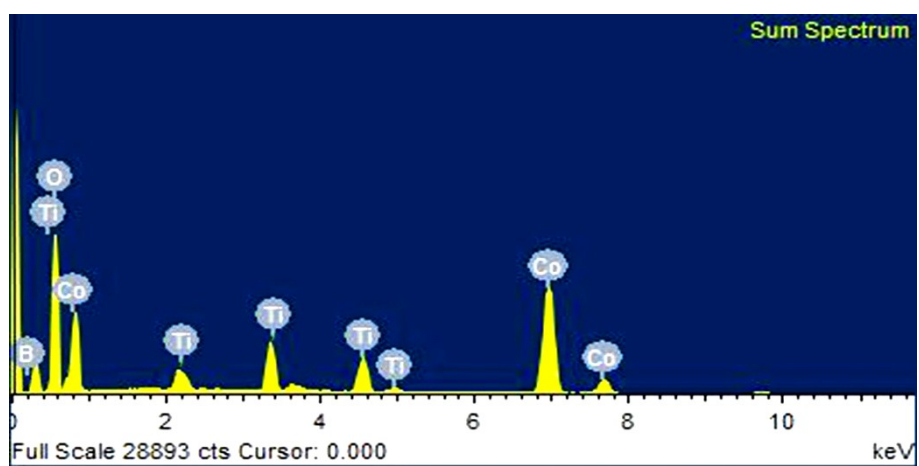


Fig. S1 EDX spectrum of Co-Bi/Ti.

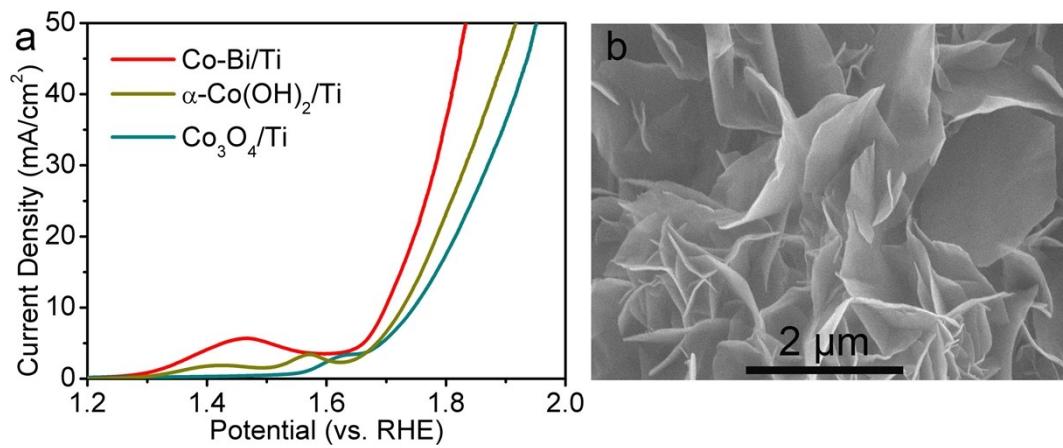


Fig. S2 (a) LSV curves of Co-Bi/Ti, α -Co(OH)₂/Ti, and Co₃O₄/Ti for OER in 0.1M KBi. (b) SEM image of Co₃O₄/Ti.

Table S1 Comparison of OER performance for Co-Bi/Ti with other non-noble-metal OER electrocatalysts in neutral or near-neutral media.

Catalyst	j (mA cm ⁻²)	η (mV)	Electrolyte	Ref.
Co-Bi/Ti	5	430	0.1 M K-Bi	This work
	10	469	0.1 M K-Bi	
Co-Bi NS/G	10	~490	0.1 M PBS	1
Co-Pi/ITO	1	410	0.1 M PBS	2
Co-Pi/ITO	1	483	0.1 M PBS	3
Co(PO ₃) ₂	10	590	0.1 M PBS	4
Co(OH) ₂	1	710	0.1 M PBS	5
CoHCF	1	580	0.05 M PBS	6
Co-Bi/FTO	1	390	1 M K-Bi	7
Co ₃ O ₄ /SWNTS	5	~700	0.1M PBS	8
Ni-Bi film/ITO	1	~425	0.1 M Bi	9
Ni-Bi film/FTO	0.6	618	0.1 M Na-Bi	10
NiO _x -en/FTO	1	~510	0.6 M Na-Bi	11
NiO _x -Bi	1	~650	0.5 M K-Bi	12
NiO _x -Fe-Bi	5	~552		
Fe-based film/ITO	10	600	0.5 M Na-Bi	13
CuO/FTO	1	~550	0.1 M K-Bi	14
Cu-Bi/FTO	1	~530	0.2 M Na-Bi	15

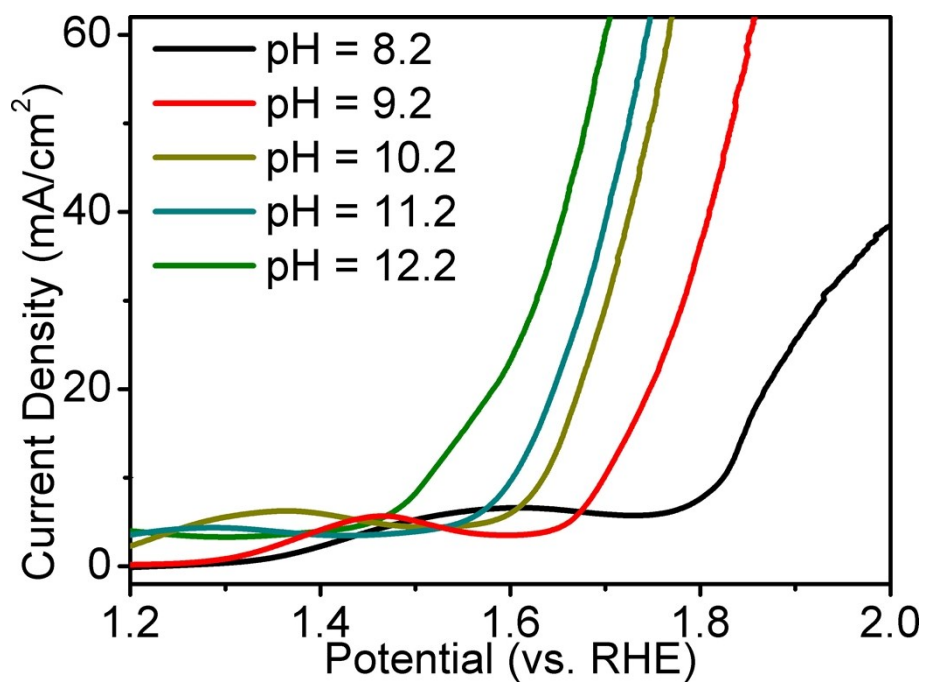


Fig. S3 LSV curves of Co-Bi/Ti for OER in 0.1M K-Bi with different pH.

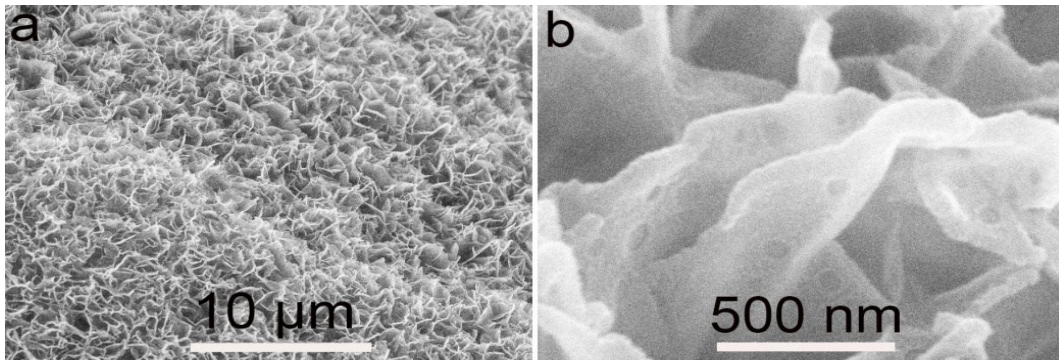


Fig. S4 SEM images of post-OER Co-Bi/Ti.

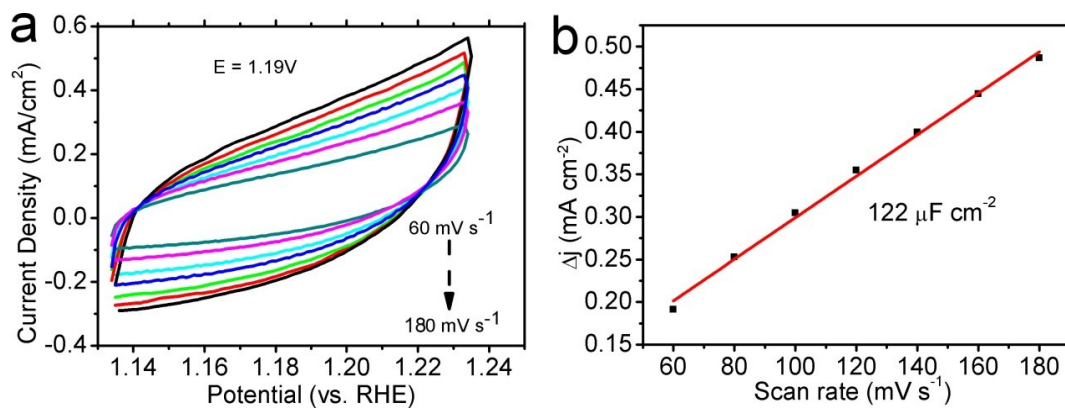


Fig. S5 (a) Cyclic voltammograms for Co-Bi/Ti in the non-faradaic capacitance current range at scan rates of 60, 80, 100, 120, 140, 160, and 180 mV s⁻¹. (b) Capacitive currents for Co-Bi/Ti as a function of scan rate.

References

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